

SiGe - Silicon Germanium

Electrical properties

Basic Parameter

$\text{Si}_{1-x}\text{Ge}_x$		Remarks	Referens
see also Si. Electrical properties and Ge. Electrical properties			
Breakdown field	$<3 \cdot 10^5 \text{ V/cm}$	300 K	Schaffler F. et al.(2001)
Mobility electrons μ_n	$\approx (1396-4315x) \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$	$0 \leq x \leq 0.3$, 300 K	
Mobility holes μ_p	$\approx (450-865x) \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$	$0 \leq x \leq 0.3$, 300 K	
Diffusion coefficient electrons	$(36-112x) \text{ cm}^2/\text{s}$	$0 \leq x \leq 0.3$, 300 K	
Diffusion coefficient holes	$(12-22x) \text{ cm}^2/\text{s}$	$0 \leq x \leq 0.3$, 300 K	
Electron thermal velocity	$\approx 2.4 \cdot 10^5 \text{ m/s}$ ($x < 0.85$)	300 K	
	$\approx 3.1 \cdot 10^5 \text{ m/s}$ ($x > 0.85$)		
Hole thermal velocity	$(1.65+0.25x) \text{ m/s}$	300 K	

